IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Sung Chul Kang, et al.)) Group Art Unit: 1752)))) Examiner: Chu, John S. Y.
Serial No.:	10/750,845	
Filed:	January 5, 2004	
or: PHOTORESIST COMPOSITION FOR MULTI-MICRO NOZZLE HEAD COATER)

AMENDMENT AND RESPONSE

onter 2/2007

VIA EFS Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

This Amendment and Response is in response to the Final Office Action dated September 28, 2007.

Please amend the application as follows: